

DO NOT ENTER: /G.N.R./ (06/25/2010)

PATENT APPLICATION

/G. Nagesh Rao/ (06/25/2010)

**RESPONSE UNDER 37 CFR §1.116
EXPEDITED PROCEDURE
TECHNOLOGY CENTER ART UNIT 1792**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Makoto IIDA et al.

Group Art Unit: 1792

Application No.: 10/586,953

Examiner: G. RAO

Filed: July 25, 2006

Docket No.: 128832

For: A SILICON SINGLE CRYSTAL, A SILICON WAFER, AN APPARATUS FOR
PRODUCING THE SAME, AND A METHOD FOR PRODUCING THE SAME

AMENDMENT AFTER FINAL REJECTION UNDER 37 CFR §1.116

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the March 24, 2010 Office Action, please consider the following:

Amendments to the Claims as reflected in the listing of claims; and

Remarks.